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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/676,695	09/30/2003	Fu-Chieh Hsu	MST-013-1D	8152
22888	7590 10/28/2004	EXAMINER		INER
BEVER HOFFMAN & HARMS, LLP TRI-VALLEY OFFICE 1432 CONCANNON BLVD., BLDG. G			WILSON, ALLAN R	
			ART UNIT	PAPER NUMBER
	E, CA 94550		2815	- -
			DATE MAILED: 10/28/2004	

Please find below and/or attached an Office communication concerning this application or proceeding.

•		Application No.	Applicant(s)			
Office Action Summary		10/676,695	HSU, FU-CHIEH			
		Examiner	Art Unit			
		Allan R. Wilson	2815			
Period fo	The MAILING DATE of this communication a or Reply	ppears on the cover sheet with the c	correspondence address			
THE - External after - If the - If NO - Failu Any I	ORTENED STATUTORY PERIOD FOR REF MAILING DATE OF THIS COMMUNICATION nsions of time may be available under the provisions of 37 CFR SIX (6) MONTHS from the mailing date of this communication. It period for reply specified above is less than thirty (30) days, a reperiod for reply is specified above, the maximum statutory perior to reply within the set or extended period for reply will, by state reply received by the Office later than three months after the mailed patent term adjustment. See 37 CFR 1.704(b).	1. 1.136(a). In no event, however, may a reply be tineply within the statutory minimum of thirty (30) day will apply and will expire SIX (6) MONTHS from ute, cause the application to become ABANDONE	nely filed rs will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status						
1)⊠	□ Responsive to communication(s) filed on					
2a)□	This action is FINAL . 2b) This action is non-final.					
3)[Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Dispositi	on of Claims					
5)□ 6)⊠ 7)⊠	Claim(s) <u>1-12</u> is/are pending in the application 4a) Of the above claim(s) <u>1 and 2</u> is/are with the Claim(s) <u></u> is/are allowed. Claim(s) <u>3-5 and 7-11</u> is/are rejected. Claim(s) <u>6 and 12</u> is/are objected to. Claim(s) <u></u> are subject to restriction and	drawn from consideration.				
Applicati	on Papers					
10)	The specification is objected to by the Examination The drawing(s) filed on is/are: a) and a splicant may not request that any objection to the Replacement drawing sheet(s) including the correct the oath or declaration is objected to by the specific	ccepted or b) objected to by the later drawing(s) be held in abeyance. See ection is required if the drawing(s) is objection	e 37 CFR 1.85(a). jected to. See 37 CFR 1.121(d).			
Priority u	ınder 35 U.S.C. § 119					
12) <u></u> a)[Acknowledgment is made of a claim for foreign All b) Some * c) None of: 1. Certified copies of the priority docume 2. Certified copies of the priority docume 3. Copies of the certified copies of the priority docume application from the International Bure see the attached detailed Office action for a list	nts have been received. nts have been received in Application in the contraction in the contract of the contr	on No ed in this National Stage			
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Attachment	• •	p p				
2) 🔲 Notice 3) 🔯 Inform	e of References Cited (PTO-892) e of Draftsperson's Patent Drawing Review (PTO-948) nation Disclosure Statement(s) (PTO-1449 or PTO/SB/0 · No(s)/Mail Date <i>0903</i> .	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal P 6) Other:				

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DETAILED ACTION

Claim Objections

Claim 3 is objected to because of the following informalities: Claim 3 recites the limitation "body regions" in next to last line. There is insufficient antecedent basis for this limitation in the claim. Appropriate correction is required.

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 3-5 and 7-9 are rejected under 35 USC § 102(b) as being anticipated by Subbanna, U.S. Patent No. 5,789,286.

With regards to claim 3, Subbanna illustrates in figures 1 and 2 (entire document) forming a buried region 13 having a first conductivity type N below an upper surface of a semiconductor region 11 of a semiconductor substrate 10, the semiconductor region having a second conductivity type P, opposite the first conductivity type; and forming a field-effect transistor 16 in the semiconductor region over the buried region, wherein a depletion region MD is located between the buried region and source 21, drain 22 and body regions 23 of the field-effect transistor.

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With regards to claims 4 and 5, Subbanna discloses in col. 4, lines 34-42, the buried region 13 is formed by an ion implantation step, wherein the buried region is implanted through a first mask.

With regards to claim 7, Subbanna illustrates in figs. 1 and 2 forming one or more shallow trench isolation regions 12 that extend a first depth d into the semiconductor substrate.

With regards to claim 8, Subbanna illustrates in fig. 2 implanting the buried region 13 such that the buried region has a top interface "j" located at or above the first depth in the semiconductor substrate, and a bottom interface located below the first depth in the semiconductor substrate.

With regards to claim 9, Subbanna discloses in col. 4, lines 31-33, the field-effect transistor 16 is fabricated using a process compatible with a standard CMOS process.

Claims 3, 10 and 11 are rejected under 35 USC § 102(b) as being anticipated by Kenney, U.S. Patent No. 5,264,716.

With regards to claim 3, Kenney illustrates in figures 1-12, particularly figure 1, (entire document) forming a buried region 32 having a first conductivity type N below an upper surface of a semiconductor region 12 of a semiconductor substrate 10, the semiconductor region having a second conductivity type P, opposite the first conductivity type; and forming a field-effect transistor 14 in the semiconductor region over the buried region, wherein a depletion region is located between the buried region and source 18, drain 20 and body regions 16 of the field-effect transistor.

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With regards to claim 10, Kenney illustrates in fig. 1 forming a well region 24 having the first conductivity type N in the semiconductor substrate 10, wherein the buried region 32 contacts the well region.

With regards to claim 11, Kenney illustrates in fig. 1 forming a deep well region 24 having the first conductivity type N in the semiconductor substrate 10, wherein the deep well region is located below and continuous with the buried region 32.

Allowable Subject Matter

Claims 6 and 12 are objected to as being dependent upon a rejected base claim, but would be allowable if rewritten in independent form including all of the limitations of the base claim and any intervening claims.

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure: Hsu et al. (illustrates SRAM with a buried layer).

Field of Search	Date
U.S. Class and subclass:	
438/238, 239, 386	October 25, 2004
Other Documentation:	
None	N/A
Electronic data base(s):	
EAST (USPAT, US-PGPUB, JPO, EPO, Derwent, IBM TDB)	October 25, 2004

Any inquiry concerning this communication or earlier communications from an examiner should be directed to Primary Examiner Allan Wilson whose telephone number is (571) 272-1738. Examiner Wilson can normally be reached 7:00-4:00 Monday-Friday.

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If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas can be reached on (571) 272-1664. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Allan R. Wilson

O. Will

Primary Examiner October 25, 2004